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Dated: March 22, 2007

Signature:

Docket No.: REGIM 3.3-089

(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Feltin et al.

Application No.: 10/573,463

Group Art Unit: 2812

Filed: December 1, 2006

Examiner: Not Assigned

For: METHOD OF PRODUCING SELF-

SUPPORTING SUBSTRATES COMPRISING

III-NITRIDES BY MEANS OF

HETEROEPITAXY ON A SACRIFICIAL

LAYER

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Dear Sir:

It is respectfully requested that the references listed on the enclosed form be made of record and considered with respect to the above-referenced U.S. patent application. A copy of each non-US reference is enclosed. Submission of the present Information Disclosure Statement should not be taken as admission that the cited references are legally available prior art or that the same are pertinent or material.

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Dated: March 22, 2007

Respectfully supmitted,

Registration No.: 32,016 LERNER, DAVID, LITTENBERG,

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PTO/SB/08A/B (09-06)

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

Sheet 1 of

Complete if Known				
Application Number	10/573,463-Conf. #9267			
Filing Date	December 1, 2006			
First Named Inventor	Eric Pascal Feltin			
Art Unit	2812			
Examiner Name	Not Yet Assigned			
Attorney Docket Number	REGIM 3.3-089			

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No.1	Document Number Number-Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear

1

FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No.1	Foreign Patent Document Country Code ³ -Number ⁴ -Kind Code ⁵ (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	7°

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	CA	Frayssinet, Beaumont, Faurie, Gibart, Makkai, Lefebvre and Valvin, "Micro Epitaxial Lateral Overgrowth of GaN/sapphire by Metal Organic Vapour Phase Epitaxy", MRS Internet J. Nitride Semicond. Res. 7, 8 (2002), pages 1-7.			

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